

AMENDMENTS TO THE SPECIFICATION

Please amend the 1st paragraph of page 24 of the present specification as follows:

Examples of the material of the thin film include metals such as aluminum, zinc, nickel, zirconium, gold, ~~silver~~, copper, tin, indium, titanium and chromium; metal oxides such as silicon oxide, aluminum oxide, magnesium oxide, and zirconium oxide; metal nitrides such as SiN, CrN, TiN and TiAlN; and materials a typical composition of which is C_xH_y (which may be an amorphous carbon film). Of these materials, an amorphous carbon film causes the adhesiveness thereof to the thin film to be remarkably improved.